

Docket No.: M4065.0453/P453-B  
(PATENT)

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

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In re Patent Application of:  
Eugene P. Marsh, et al.

Application No.: TBD

Group Art Unit: 2822

Filed: September 8, 2003

Examiner: M. Trinh

For: PROCESS FOR LOW TEMPERATURE  
ATOMIC LAYER DEPOSITION OF RH

**FIRST PRELIMINARY AMENDMENT**

**Box Patent Application**  
Commissioner for Patents  
Washington, DC 20231

Dear Sir:

Prior to examination on the merits, please amend the above-identified U.S. patent application as follows:

**In the Specification**

On page 2, before "Field of the Invention," please insert -- This application is a divisional of application Serial No. 10/283,316, filed October 30, 2002, which is turn is a divisional of Serial No. 09/884,997, filed on June 21, 2001, the disclosures of both of which are incorporated by reference herein.--

**In the Claims**

Please cancel claims 1-54.